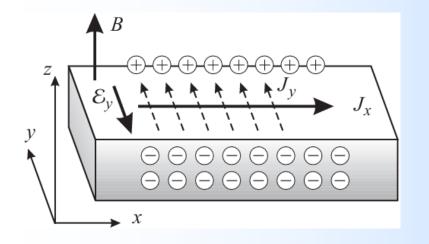
Physics of Semiconductors (4)

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2013/5/8

Hall effect

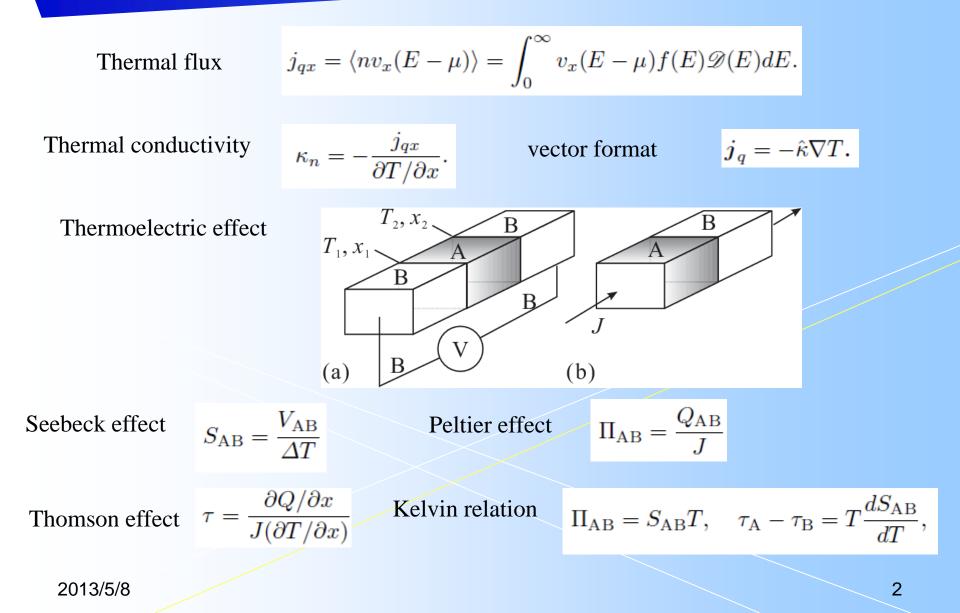


Hall coefficient :

$$R_{\rm H} = \frac{\mathcal{E}_y}{J_x B_z}$$

$$R_{\rm H} = -\frac{1}{ne} \frac{\langle \tau^2 \rangle_E}{\langle \tau \rangle_E^2} = \frac{1}{n(-e)} \frac{\Gamma(2s+5/2)\Gamma(5/2)}{(\Gamma(s+5/2))^2} = \frac{r_{\rm H}}{n(-e)}$$

Thermal transport and electric transport



Boltzmann equation and thermoelectric coefficients

Material specific Seebeck coefficient

$$S_{\rm A}(T) \equiv \int_0^T \frac{\tau_{\rm A}(T')}{T'} dT'$$

$$S_{\rm AB} = S_{\rm A} - S_{\rm B}$$

Boltzmann equation for steady states

$$\boldsymbol{v} \cdot \nabla f + \frac{\boldsymbol{F}}{m} \nabla_{\boldsymbol{v}} f = -\frac{f - f_0}{\tau(E)}$$

Replace
$$f$$
 in LHS with f_0 .

$$\nabla f_0 = \nabla T \frac{\partial f_0}{\partial T}$$
$$a = -\frac{E - E_F}{k_B T}$$

$$\frac{\partial f_0}{\partial T} = \frac{\partial f_0}{\partial E} \frac{\partial E}{\partial a} \frac{\partial a}{\partial T} = \frac{\partial f_0}{\partial E} (-k_{\rm B}T) \frac{E - E_{\rm F}}{k_{\rm B}T^2} = \frac{\partial f_0}{\partial E} \frac{E_{\rm F} - E}{T}$$

$$\nabla f_0 = \nabla T \frac{E_{\rm F} - E}{T} \frac{\partial f_0}{\partial E}.$$
$$\nabla_v f_0 = \nabla_v E \frac{\partial f_0}{\partial E} = mv \frac{\partial f_0}{\partial E}.$$

$$f = f_0 - \tau(E) \boldsymbol{v} \cdot \left[-e\mathbf{E} + \frac{E_{\mathrm{F}} - E}{T} \nabla T \right] \frac{\partial f_0}{\partial E}.$$

Boltzmann equation and thermoelectric coefficients

$$j_{x} = -e\langle nv_{x}\rangle = -e\int_{0}^{\infty} v_{x}f(E)\mathscr{D}(E)dE = e\int_{0}^{\infty} v_{x}^{2}\tau \left[-e\mathcal{E}_{x} + \frac{E_{F} - E}{T}\frac{\partial T}{\partial x}\right]\frac{\partial f_{0}}{\partial E}\mathscr{D}(E)dE.$$

$$j_{x} = 0,$$

$$S = \frac{\mathcal{E}_{x}}{\partial T/\partial x} = \int_{0}^{\infty} \frac{E_{F} - E}{eT}\frac{\partial f_{0}}{\partial E}\mathscr{D}(E)dE / \int_{0}^{\infty} v_{x}^{2}\tau\frac{\partial f_{0}}{\partial E}\mathscr{D}(E)dE$$

$$1 \left[\int_{0}^{\infty} \int_{0}^{\infty} v_{x}^{2}\tau\frac{\partial f_{0}}{\partial E}\mathscr{D}(E)dE - \int_{0}^{\infty} \int_{0}^{\infty} v_{x}^{2}\tau\frac{\partial f_{0}}{\partial E}\mathscr{D}(E)dE\right]$$

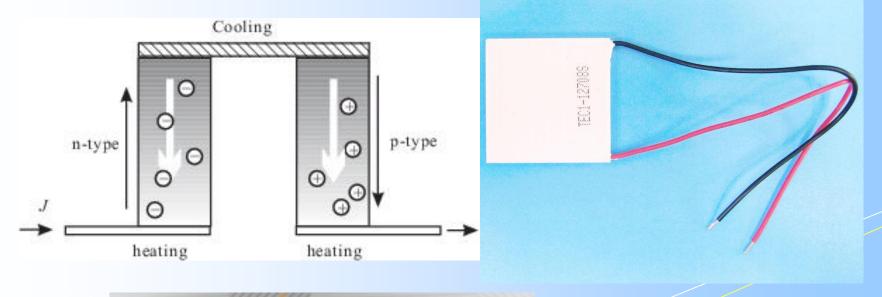
$$\begin{split} S &= \frac{\mathcal{E}_x}{\partial T/\partial x} = \int_0^\infty \frac{E_{\rm F} - E}{eT} \frac{\partial f_0}{\partial E} \mathscr{D}(E) dE \bigg/ \int_0^\infty v_x^2 \tau \frac{\partial f_0}{\partial E} \mathscr{D}(E) dE \\ &= \frac{1}{eT} \left[E_{\rm F} - \int_0^\infty \tau E^2 \frac{\partial f_0}{\partial E} \mathscr{D}(E) dE \bigg/ \int_0^\infty \tau E \frac{\partial f_0}{\partial E} \mathscr{D}(E) dE \right]. \end{split}$$

Maxwellian approximation $\partial f_0 / \partial E = -f_0 / k_{\rm B} T$,

 $\tau \propto E^s$

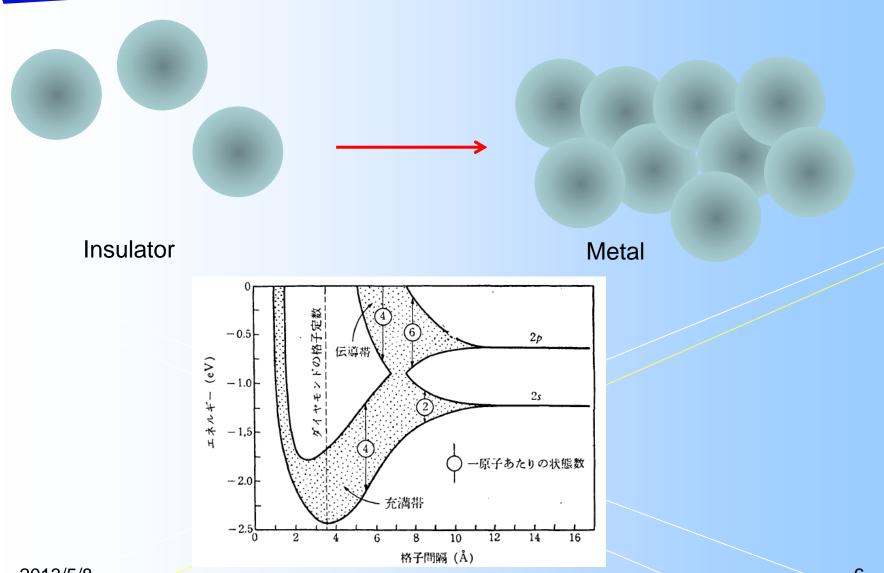
$$S = -\frac{1}{eT} \left[\frac{\langle \tau E \rangle_E}{\langle \tau \rangle_E} - E_F \right] = -\frac{1}{eT} \left[\left(\frac{5}{2} + s \right) k_B T - E_F \right]$$

Peltier device





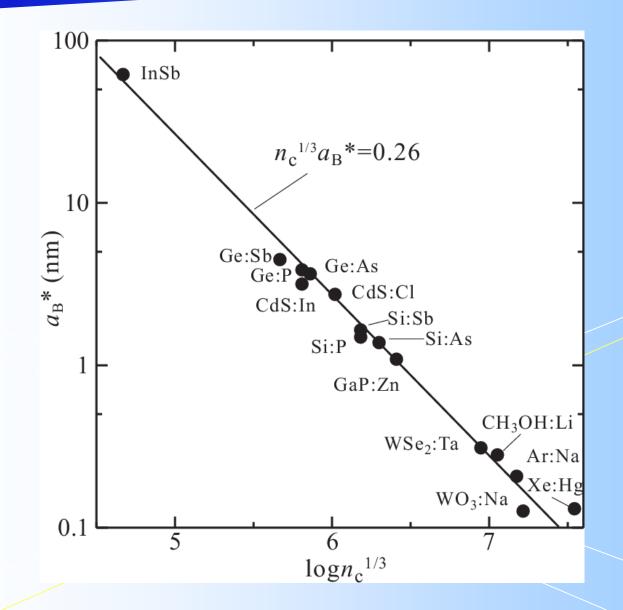
Metal-insulator transition



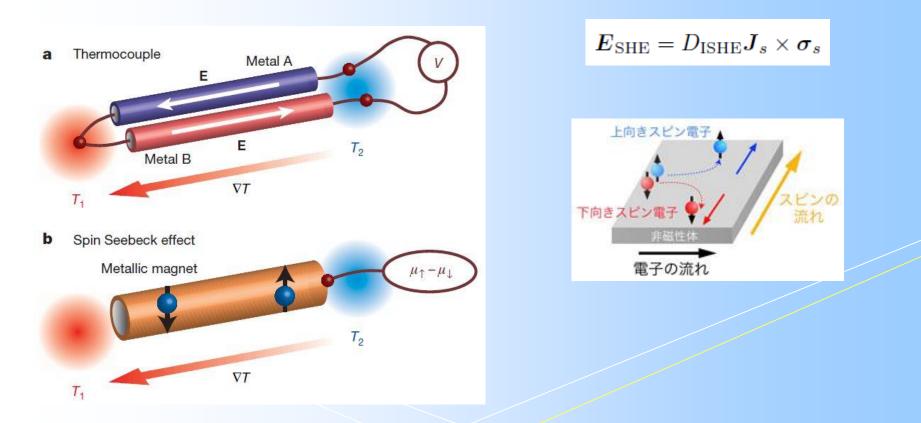
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Metal-insulator transition

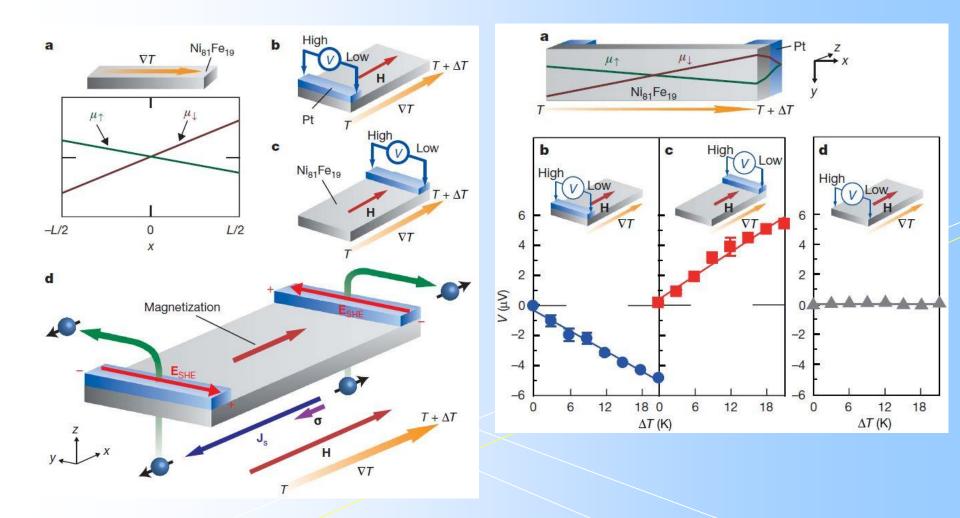


Spin Seebeck effect



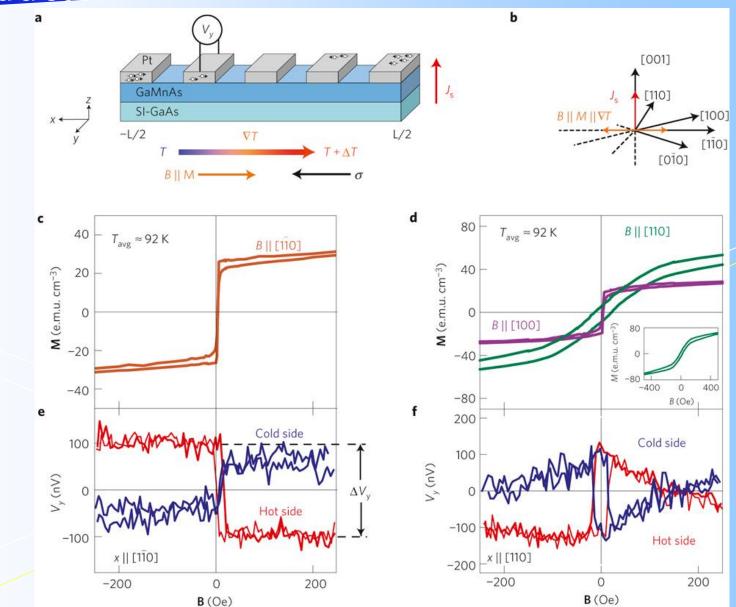
K. Uchida, S. Takahashi, K. Harii, J. Ieda, W. Koshibae, K. Ando, S. Maekawa and E. Saitoh, Nature **455**, 778 (2008).

Spin Seebeck effect

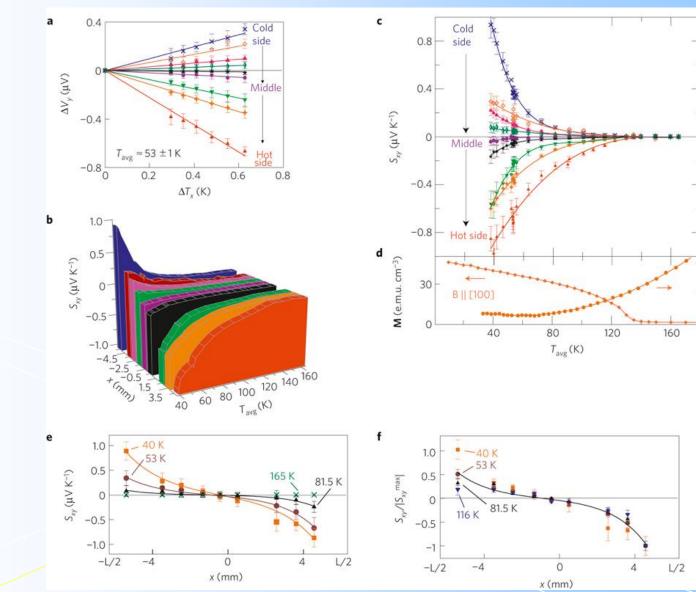


Spin Seebeck effect (?) in a ferromagnetic semiconductor

Jarowski *et al.* Nature Materials **9**, 898 (2010)



Spin Seebeck effect (?) in a ferromagnetic semiconductor

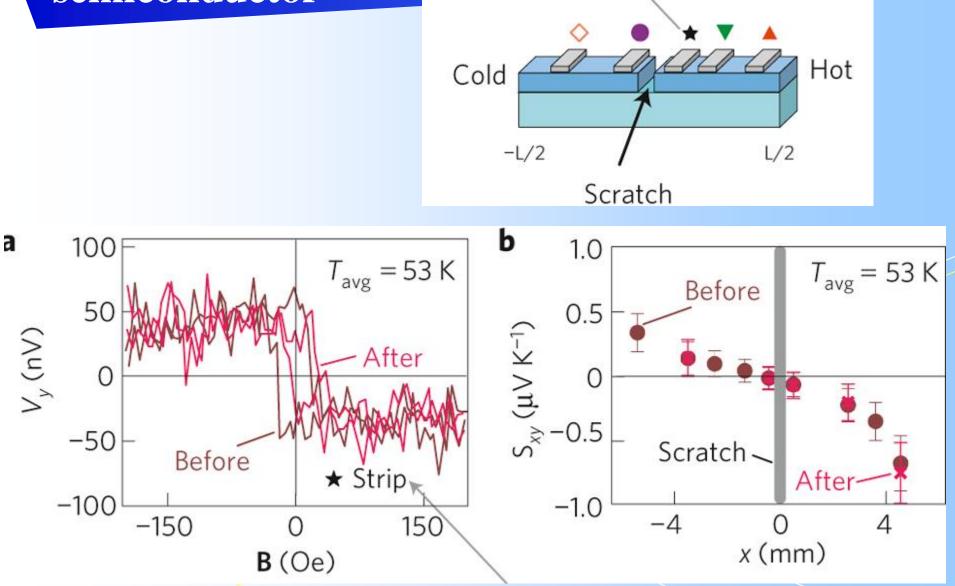


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α_{xx} (μV K⁻¹)

Spin Seebeck effect (?) in a ferromagnetic semiconductor



Exercise

1. p-Ge has Seebeck coefficient of 300μ V/K and n-type Bi₂Te₃ –230 μ V/K. If one makes a thermocouple from these two materials, how high is the voltage caused by the temperature difference of 50K.

2. Obtain expressions for electron mobility and for diffusion constant in terms of the conductivity and the Hall coefficient.

3. Obtain the Mott's criterion $n_c^{1/3}a_B^*=0.26$ along the following guide.

Obtain the condition for the Schrodinger equation with screened Coulomb potential to have bound state with variational method.

$$\begin{bmatrix} -\frac{\hbar^2}{2m^*} \nabla^2 - \frac{e^2}{4\pi\varepsilon_0 \varepsilon r} e^{-\frac{r}{\lambda}} \end{bmatrix} \psi(\mathbf{r}) = E\psi(\mathbf{r}), \qquad \lambda = \sqrt{\frac{2\varepsilon\varepsilon_0 E_{\rm F}}{3ne^2}}$$
$$E_F = \frac{\hbar^2}{2m^*} (3\pi^2 n)^{2/3}$$